



## SPRINT FLEX

Roll-to-Roll Thin Film Deposition System



Designed for a wide range of flexible roll-to-roll deposition processes, full range of deposition sources and multiple substrate options, with preci-sion single side touch material handling.

### Typical Applications

- Molybdenum

- CdS

- CIGS

- TCO

- CdTe

Free span roll-to-roll configuration with deposition on both front and back side of the substrate in a single pass to provide maximum flexibility.

Configurable with up to 4 front and 3 back side deposition sources with independent recipe driven control over each source including the ability to execute multiple passes alternating materials.

Substrate heating and pretreatment options such as ion bombardment, AC/DC/RF or plasma bombardment to optimize surface energy of substrates

# Flexible Configurations based on Mustang<u>'</u>s proven industrial system platform

#### **Dual direction deposition**

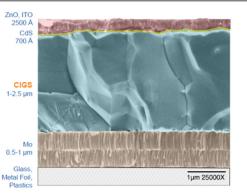
- .01 3 M/min precision roll speed
- Substrates 20-40CM wide / 20-150 M lengths
- Custom and larger substrate options available

#### Base vacuum 10x-7

- Mechanical or dry roughing pumps
- · Oil diffusion or Turbo pumps
- Cryogenic vacuum / water pump

#### Film thickness monitoring

Sprint Heat rapid annealing



## Custom Size PVD Planar or Rotatable Cathodes



#### **Deposition Uniformity (+/- 3%)**

Ag, Al, Cr, Cu, ITO, Ni, NiCr, NiV, Ti, SS,  $Al_2O_3$ ,  $Nb_2O_5$ , SiN, SiO2,  $Ta_2O_2$ , TiN,  $TiO_2$ , ZnO

#### **Applications**

PV-Mo, CIG, CIGS, TCO(ITO/ZnO)

TCO Touch Screen

OLED cathode layer, evaporation of low



Configuration	Process specific configurations for Sputter, Co-Evaporation, Selenium, Thermal Annealing and custom.	
Orientation	Horizontal or Vertical roll to roll free span web material orientation	
Web materials	Mylar, PET, BOPP, Kapton, thin metals, etc. System is not web material dependent.	
Maximum web temperature	350° C.	
Ultimate Vacuum	Better than $8.0 \times 10^{-7}$ Torr within 24 hours or less.	
Operating Vacuum	Between 9 x 10 <sup>-7</sup> & 3.5 x 10 <sup>-3</sup> Torr. (process dependent)	
System Dimensions	3.6 m (11' 10") wide by 3.9 m (12' 10") deep by 3.04 m (10.0') tall.	
Utilities	Air: 80 psi (5.5 bar) @ 20 cfm	
	Electrical: 480V/3P/50Hz/250 FLA, fully outfitted, other power configurations available.	
	Water: 50 GPM (220 liters / min) @ 60-800 F (15-26 O	
	Grounding: Two (2) ¾" diameter copper clad steel rods, driven through the floor, into the earth, by 8'. Ground rods to be placed at 6 feet apart with a re-sistance reading of less than 3 ohms.	

Chemical composition	ZnO:Al	In <sub>2</sub> O <sub>3</sub> :SnO <sub>2</sub>
Sheet resistance (Ω/□)	15	10
Resistivity (10 <sup>-4</sup> Ω-cm)	15	10
Thickness (nm)	1000	1000
Transmission (%) (500-900nm)	>75	>80
Uniformity, resistivity (%)	< 2	< 2
Uniformity, transmission (%)	< 1	< 1
Uniformity, thickness (%)	<3	<3

Chemical composition	Мо
Sheet resistance (Ω/□)	0.2
Resistivity (10 <sup>-5</sup> Ω-cm)	2
Thickness (nm)	1000
Uniformity, resistivity (%)	< 2
Uniformity, thickness (%)	<3
Coating Stress	Films are slight- ly compressive